

3RD INTERNATIONAL WORKSHOP ON HIV & ADOLESCENCE CHALLENGES & SOLUTIONS

NAIROBI, KENYA • 2-4 OCTOBER 2019



WORKSHOP CHAIRS



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Join us for the 3rd International Workshop on HIV & Adolescence in Nairobi, Kenya!

The International Workshop on HIV & Adolescence is a key platform that brings together researchers, implementers, youth and other stakeholders working with adolescents affected by and living with HIV. Through developing collaborations and solutions, this workshop aims to optimize the health and overall well-being of all adolescents.

- Get the latest updates in **informative plenary sessions**
- Join the **interactive roundtable discussions** and **debates**
- Present your own data and discuss with peers in the **abstract sessions**
- **Network** and **connect** with potential collaborators and partners

#HIVadolescence



THE PREVIOUS EDITION IN NUMBERS:



Attendees from over **26** countries



221 Submitted
abstracts
2018

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ABSTRACT SUBMISSION

SUBMIT YOUR ABSTRACT! Deadline June 28th
Visit the conference website for more details.

ORGANIZER



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